Supporting information for

# Integrated Passivation Strategy Using Multifunctional Additives for

## **Tin-Lead Mixed Perovskite Solar Cells**

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### Experimental

### **Materials and Methods**

#### Materials

Anhydrous solvents, including N, N-dimethylformamide (DMF), dimethyl sulfoxide (DMSO), chlorobenzene (CB), and isopropanol (IPA), were obtained from Sigma-Aldrich. Lead iodide (PbI<sub>2</sub>, 99.99%) and ethylenediamine dihydroiodide (EDAI<sub>2</sub>, 99.99%) were sourced from TCI. Formamidinium iodide (FAI, 99.99%) and methylammonium iodide (MAI, 99.99%) were acquired from Great Cell Solar. Bathocuproine (BCP, >99%), phenyl-C<sub>61</sub>-butyric acid methyl ester (PC<sub>61</sub>BM, >99%), and PEDOT:PSS were purchased from Xi'an Yuri Solar Co., Ltd. N-(4-Cyanophenyl) guanidine hydrochloride (CG) was obtained from Bide Pharmatech Ltd. Silver (Ag) and tin fluoride (SnF<sub>2</sub>) were sourced from Sigma-Aldrich, while tin iodide (SnI<sub>2</sub>) was provided by Energy Chemical. Fullerene (C60) was purchased from Liaoning Youxuan New Energy Technology Co., Ltd. Methyl sulfoxide-d6 was obtained from J&K Scientific, and ITO glass from Suzhou ShangYang Solar Technology Co., Ltd.

To prepare the undoped precursor solution, 14.2 mg of  $SnF_2$ , 85.8 mg of MAI, 216.6 mg of FAI, 415 mg of PbI<sub>2</sub>, and 335.6 mg of  $SnI_2$  were dissolved in 1000 µL of a DMF and DMSO mixture (volume ratio 7:3). The solution was stirred for 12 hours. For the doped solution, an additional 1.6-2.4 mg of CG was added to the undoped precursor solution.

To prepare the passivation solution, 5 mg of  $EDAI_2$  was dissolved in 10 mL of a 200:1 volume ratio of IPA and DMF. For the integrated passivation solution, an additional 1-3 mg of CG was added to the blank passivation solution. The solution was stirred for 24 hours.

## **Device fabrication**

The inverted (p-i-n) perovskite solar cell examined in this study features an architecture of ITO/PEDOT:PSS/Perovskite/EDAI<sub>2</sub>/PC<sub>61</sub>BM/C60/BCP/Ag. The fabrication process began with cleaning the ITO glass substrate in an ultrasonic bath, sequentially using detergent (2% in deionized water), deionized water, acetone, and isopropanol, each for 15 minutes. The cleaned substrate was then dried with N<sub>2</sub> gas and subjected to

UV-ozone treatment for 15 minutes. The PEDOT:PSS dispersion was spin-coated onto the ITO substrate and annealed at 150°C for 10 minutes. After transferring the substrates to a glovebox, the prepared perovskite precursor solution was spin-coated onto the PEDOT:PSS layer, initially at 1000 rpm for 10 seconds, then at 5000 rpm for 60 seconds. During the final 25 seconds, 500  $\mu$ L of chlorobenzene was drop-cast onto the spinning film, which was then annealed at 100°C for 10 minutes. A solution mix of CG and EDAI<sub>2</sub> was dynamically spin-coated onto the perovskite layer at 4000 rpm for 35 seconds, followed by annealing at 100°C for 5 minutes. A layer of PC<sub>61</sub>BM (3 mg/mL in chlorobenzene) was then spin-coated at 6000 rpm for 35 seconds and annealed at 100°C for 30 seconds. This was followed by the thermal evaporation of a 20 nm layer of C60 and a 6 nm layer of BCP. Finally, a 100 nm thick layer of silver (Ag) was deposited via thermal evaporation to complete the device structure.

#### Materials characterizations:

The NMR spectra were recorded using Bruker Advance 500 and Bruker Advance 400 spectrometers in DMSO-d6. UV-Vis spectra were obtained on a PerkinElmer Lambda 950 spectrometer. Steady-state and time-resolved PL spectra were measured with a Photoluminescence Spectrometer (FLS1000, Edinburgh Instruments) using a 532 nm pulsed laser as the excitation source. For film characterization, X-ray diffraction (XRD) spectra were measured with a Rigaku Smartlab. The XRD results were obtained using a focused-beam setup. Subsequently, grazing-incidence XRD (GIXRD) measurements were performed with a parallel-beam geometry, which is optimized for thin-film characterization. Additionally, prior to testing each sample, parallel-beam alignment was conducted to ensure accurate sample height calibration. The samples were then tested at incident angles of 0.3°, 0.5°, 1.0°, and 3.0°. X-ray photoelectron spectroscopy (XPS) measurements were performed on an Omicron ESCA Probe XPS spectrometer (Thermo Scientific ESCALAB 250Xi) with a survey scan pass energy of 150 eV and step size of 1 eV, and a fine scan pass energy of 20 eV with a 0.01 eV step size. Scanning electron microscopy (SEM) images were obtained using a HITACHI SU8230. FTIR spectra were recorded on a Bruker Vertex 70v. Ultraviolet photoelectron spectroscopy (UPS) spectra, used to measure the work function, were recorded on an Imaging Photoelectron Spectrometer (Axis Ultra, Kratos Analytical Ltd) with a non-monochromated He I $\alpha$  photon source (hv = 21.22 eV), using Au as a reference.

## **Device performance characterization:**

J-V measurements were performed using a Keithley 2400 source meter in ambient conditions (~20 °C and ~60% RH). Unencapsulated devices were tested in both reverse scan (0.9 V to -0.2 V, with 0.01 V steps) and forward scan (-0.2 V to 0.9 V, with 0.01 V steps), with a delay of 200 ms. Illumination was provided by an Oriel Sol3A solar simulator with an AM 1.5G spectrum, calibrated to a light intensity of 100 mW/cm<sup>2</sup> using a standard KG-5 silicon diode. A shadow mask defined the active area (0.08 cm<sup>2</sup>) during measurements. Electrochemical impedance spectroscopy (EIS) and Mott-Schottky plots were obtained using a Zahner Zennium electrochemical workstation. EQE measurements were conducted with an EnliTech (Taiwan) system, with light intensity at each wavelength calibrated using a standard single-crystal silicon photovoltaic cell. For stabilized power output (SPO) tests under illumination, the bias voltage was held at the maximum power point voltage (*Vmax*), and current density was monitored under ambient conditions without temperature control. Long-term operational stability was evaluated by placing encapsulated devices under a 1 sun equivalent LED lamp in ambient conditions (~20 °C and ~60% RH), with maximum power point data recorded every minute.



**Figure S1.** a) <sup>1</sup>H nuclear magnetic resonance (NMR) spectroscopy of phenylmethylguanidine (PG), FAI and PG+FAI. b) Schematic diagram of hydrogen bonding between FA<sup>+</sup> and CG.



Figure S2. FTIR spectrum of CG, FAI and CG+FAI.



Figure S3. FTIR spectrum of CG, CG+PbI<sub>2</sub> and CG+SnI<sub>2</sub>.



**Figure S4.** The grazing incidence X-ray diffraction (GIXRD) patterns of a) Control and b) target TLP films.



**Figure S5.** The top-view and cross-section scanning electron microscope (SEM) images of TLP-control a), b) TLP(CG) and c) TLP(CG)+CG pass-target.



**Figure S6.** The grazing incidence X-ray diffraction (GIXRD) patterns of TLP-control, TLP(CG) and TLP(CG)+CG pass-target films.



**Figure S7.** The XPS peaks of Sn 3*d* for control and target TLP films.



**Figure S8.** Ultraviolet photoelectron spectroscopy (UPS) spectra of  $PC_{61}BM$  film a) and b). c) Tauc plot of  $PC_{61}BM$  film.



**Figure S9.** Ultraviolet photoelectron spectroscopy (UPS) spectra of C60 film a) and b). c) Tauc plot of C60 film.



**Figure S10.** Ultraviolet photoelectron spectroscopy (UPS) spectra of PEDOT:PSS film a) and b).



Figure S11. Transient photovoltage (TPV) and transient photocurrent (TPC) tests of control and target devices.



**Figure S12.** Distribution of performance parameters of PSCs conversion efficiency after CG incorporation.



**Figure S13.** Distribution of performance parameters of PSCs conversion efficiency after CG incorporation and CG passivation.



**Figure S14.** Distribution of performance parameters of PSCs conversion efficiency without and with CG incorporation and CG passivation.



**Figure S15.** Encapsulated PSCs with maximum output point continuous tracking under AM1.5G illumination in ambient air.

**Table S1.** The fitting results of TRPL for Control and Target perovskite films.

	A <sub>1</sub>	$\tau_1(ns)$	A <sub>2</sub>	$\tau_2(ns)$	R <sup>2</sup>	τ <sub>ave</sub> (ns)
Control	0.6430	830	0.3570	4800	0.9983	2247
Target	0.5468	895	0.4532	8772	0.9991	4464

Table S2. The detail data of the JV curves of PSCs with CG incorporation.

	J <sub>SC</sub> (mA/cm <sup>2</sup> )	Voc (V)	FF (%)	PCE (%)
Control	32.59	0.840	76.02	20.81
1.6mg/mL	32.60	0.842	78.58	21.56
2.0mg/mL	32.73	0.853	80.59	22.50
2.4mg/mL	32.63	0.842	78.04	21.44

**Table S3.** The detail data of the JV curves of PSCs with CG incorporation and passivation.

	J <sub>SC</sub> (mA/cm <sup>2</sup> )	Voc (V)	FF (%)	PCE (%)
TLP(CG)	32.73	0.853	80.59	22.50
0.1mg/mL	32.76	0.862	80.17	22.64
0.2mg/mL	32.84	0.860	81.87	23.13
0.3 mg/mL	32.79	0.848	81.79	22.74

Table S4. The detail data of the JV curves of PSCs.

		J <sub>SC</sub> (mA/cm <sup>2</sup> )	$V_{oc}(\mathbf{V})$	FF (%)	PCE (%)
Control	Forward	32.59	0.840	76.02	20.81
	Reverse	32.40	0.829	73.38	19.71
Target	Forward	32.84	0.860	81.87	23.13
	Reverse	32.62	0.859	80.01	22.42

**Table S5.** Fitting parameters of PSCs from Nyquist plots.

	$R_S(\Omega)$	$R_{REC}(\Omega)$
Control	44.7	1559
Target	41.9	4738